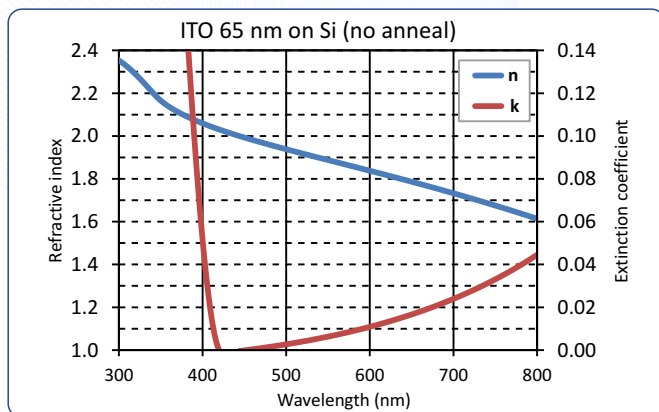
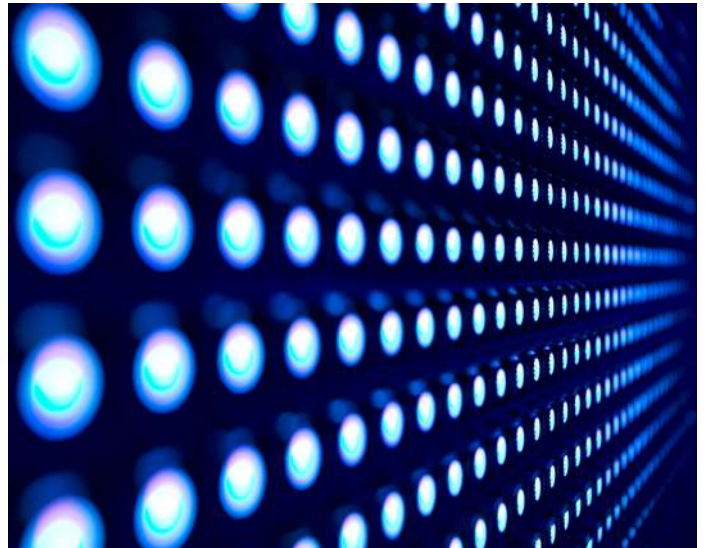


Indium Tin Oxide

Solmates Pulsed Laser Deposition process:

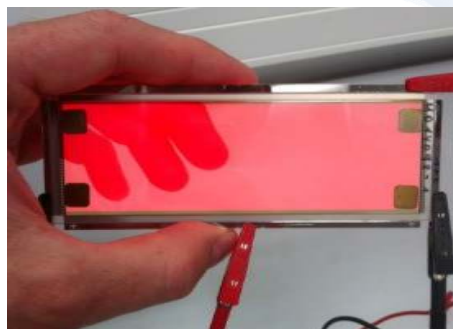
- Damage-free deposition on GaN, OLED & other organics
- Low temperature deposition, no post-anneal required
- High performance as-deposited (electrical and optical)
- Refractive index tuning and grading



Throughput indication (75 nm)

Wafer size	Wafers/hr
2"	180 - 240
4"	45 - 60
6"	20
8"	20

Demonstration of PLD damage free deposition of ITO on an OLED



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